

Artificial Intelligence for Engineering Design, Analysis and Manufacturing

Clive L. Dym, Editor

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- · theoretical work on the modeling of engineering problemsolving and design processes
- the integration of AI-based techniques with numerical analysis tools, graphics and solid modeling packages, and engineering databases
- · engineering applications of knowledge-based vision and of natural language processing

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Publishing, Subscription and Advertising Offices: Cambridge University Press, 40 West 20th Street, New York, NY 10011, USA; and (outside the US and Canada) Cambridge University Press, The Edinburgh Building, Shaftesbury Road, Cambridge CB2 2RU, England.

AI EDAM is published five times a year. Annual institutional subscription rates: US \$210.00 in the US, Canada, and Mexico; UK £120.00 + VAT elsewhere. Individual rates: US \$92.00 in the US, Canada, and Mexico; UK £55.00 + VAT elsewhere. Single part rates: US \$47.00 in the US, Canada, and Mexico; UK £28.00 + VAT elsewhere. Prices include postage and insurance.

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Printed in the United States of America.

Second class permit pending at New York, NY, and additional mailing offices. Postmaster: send address changes in the US, Canada, and Mexico to: AI EDAM: Artificial Intelligence for Engineering Design, Analysis and Manufacturing, Journals Department, Cambridge University Press, 110 Midland Avenue, Port Chester, NY 10573-4930.